Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1211	multilayer adj (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 15:12
L2	40772	positive with (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 15:12
L3	437	L1 and L2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 15:12
L4	356	L3 and @ad<"20030718"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 16:27
L5	16	("20010001703" "20020068808" "20020146638" "20030073043" "3988256" "4051271" "4491628" "4609615" "4686168" "5173393" "5234793" "5234794" "5403699" "5650261" "6524775" "6746821").PN. OR ("7045274").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2007/03/19 15:27
L6	619	(pad adj2 nitride) and (pad adj2 oxide) and (hardmask or (hard adj mask))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 16:26

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L7	594	(pad adj2 nitride) and (pad adj2 oxide) and (hardmask or (hard adj mask)) and trench	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 16:26
L8	355	(pad adj2 nitride) and (pad adj2 oxide) and (hardmask or (hard adj mask)) and (wet with etch\$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 16:27
L9	159	L8 and @ad<"20030718"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 16:27
S1	13	(("6713236") or ("6806200") or ("6033997") or ("6291315") or ("6927172") or ("6864182")).PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/03/17 11:38
S2	986	black adj silicon	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 11:39
S3	604215	mask	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 11:39
S4	623685	resist	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 11:39

S5	67	S2 and S3 and S4	US-PGPUB; USPAT;	OR	ON	2007/03/17 11:39
			USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB			
S6	60	S5 and @ad<"20030718"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 15:57
S7	1106	(pad adj2 nitride) and (pad adj2 oxide) and (mask) and (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 14:06
S8	391	(pad adj2 nitride) same (pad adj2 oxide) same (mask) same (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:26
S9	211	S8 and @ad<"20030718"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:38
S10		("20050014364").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/03/17 12:27
S11	14050	(second or additional) adj (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:38

S12	99	S7 and S11	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:38
S13	43	S12 and @ad<"20030718"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 14:07
S14	36	(pad adj2 nitride) and (pad adj2 oxide) and (mask) and (positive with (resist or photoresist))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 14:07
S15	28	(pad adj2 nitride) and (pad adj2 oxide) and (hardmask or (hard adj mask)) and (positive with (resist or photoresist))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/19 16:26
S16	20	S15 and @ad<"20030718"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 15:56
S17	13	(("6507034") or ("20040005516") or ("6713236") or ("6520844") or ("5866481") or ("5405734")).PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/03/17 14:09
S18	1211	multilayer adj (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 15:56

S19	40768	positive with (resist or photoresist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 15:56
S20	437	S18 and S19	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 15:56